

## GaAs MMIC Absorptive SP8T Switch Chip, 0.5-18GHz

### Performance characteristics

- Frequency range: 0.5 - 18GHz
- Positive control, full shutdown, integrated TTL
- Insertion loss : 4.0 dB @ 18GHz typ.
- Isolation: 50dB
- On/off state standing wave ratio : 1.5 :1
- Chip size: 2.15 x1.9 x 0.1mm

### Product Introduction

GSW-00188T-N-PDM is an absorptive single-pole eight-throw switch chip with 50Ω matching at the input/output end and a frequency range of 0.5~18 GHz .Speed 35 ns, 1dB compression input power +2 5 dBm. The chip adopts -5V power supply, + 5V /0V positive level control (compatible with +3.3V), the product has full off ISW-000188T-N-PDM and ISW-000188T-N-PD are mirror versions of each other.

### Use limit parameters

Control voltage range	-0.5V ~ + 6V
Supply voltage range	-6V
Maximum input power	+27dBm
Operating temperature	-55 ~ +85°C
storage temperature	-65 ~ +150°C

Exceeding any of these maximum limits may cause permanent damage.

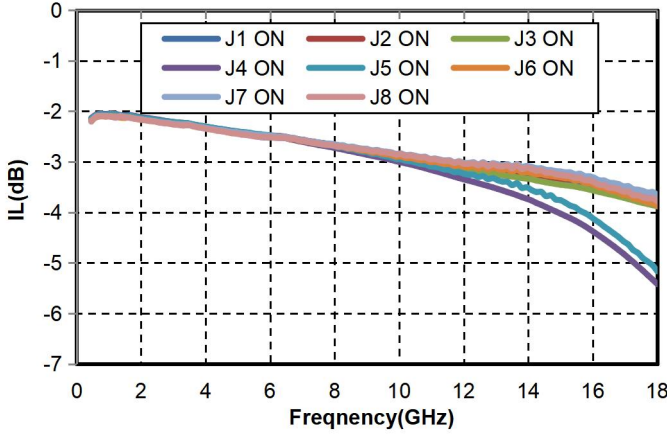
### Electrical performance parameters ( TA = +25°C, VEE = -5V )

index	Minimum	Typical Value	Maximum	unit
Frequency Range	0.5-18			GHz
Insertion loss @18GHz	-	4.0	-	dB
Isolation	-	50	-	dB
On-state input return loss	-	15	-	dB
On-state output return loss	-	14	-	dB
Off-state output return loss	-	16	-	dB
P-1@0.5~18GHz	-	25	-	dBm
Switching speed	-	35	-	ns
Control current	-	500	-	uA
Input high level voltage	+3.0	+3.3	+5	V
Input low level voltage	0	-	+ 0.8	V
voltage	-	-5	-	V
Quiescent Current	-	20	-	mA

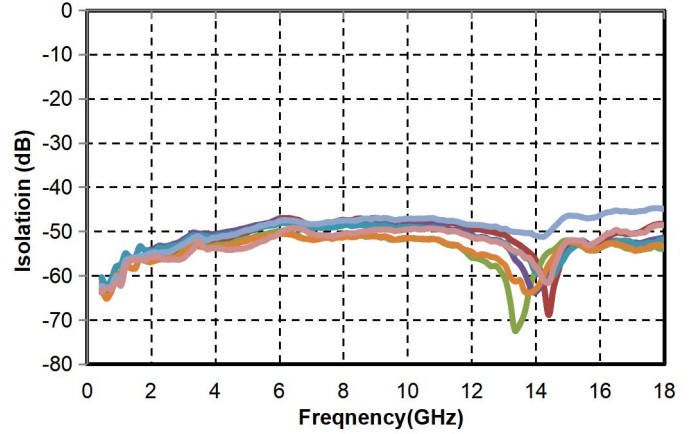
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Main index test curve

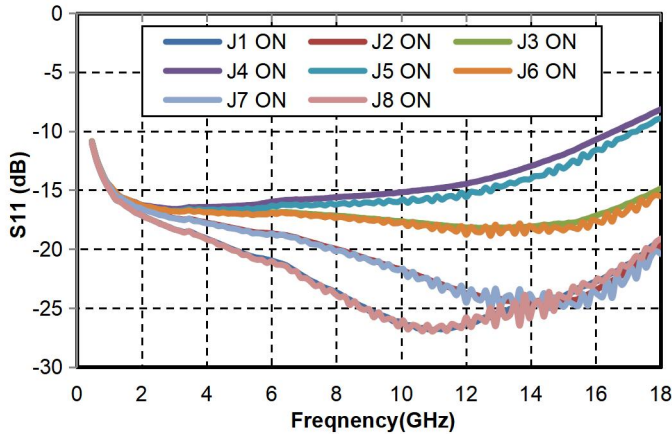
Insertion Loss vs. Operating Frequency



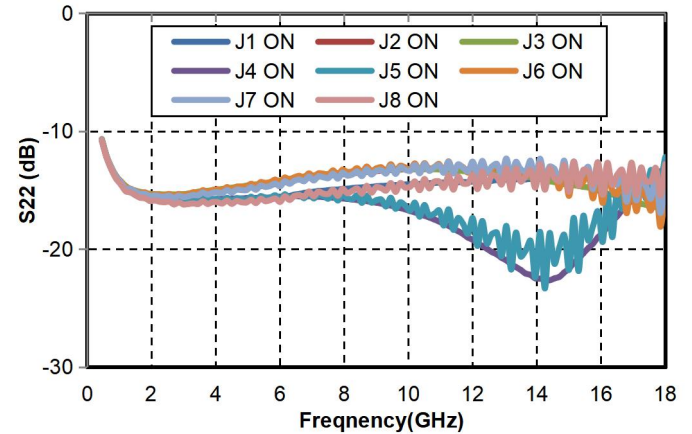
Isolation vs. Operating Frequency



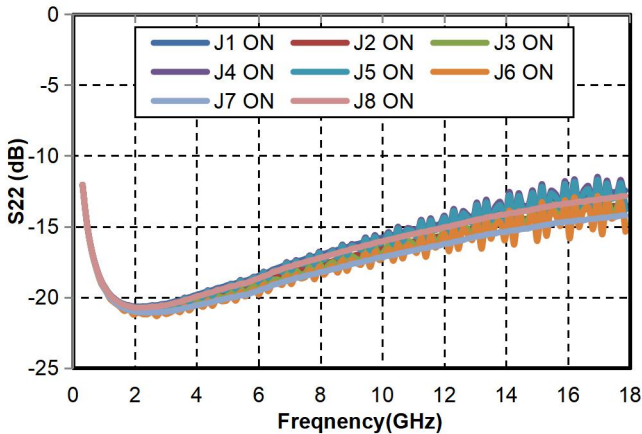
Input Return Loss vs. Operating Frequency  
( On State )



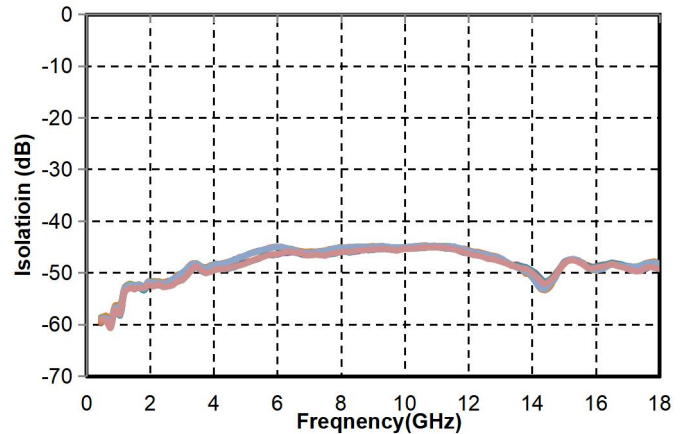
Output Return Loss vs. Operating Frequency  
( On State )



Output Return Loss vs. Operating Frequency  
( Off State )

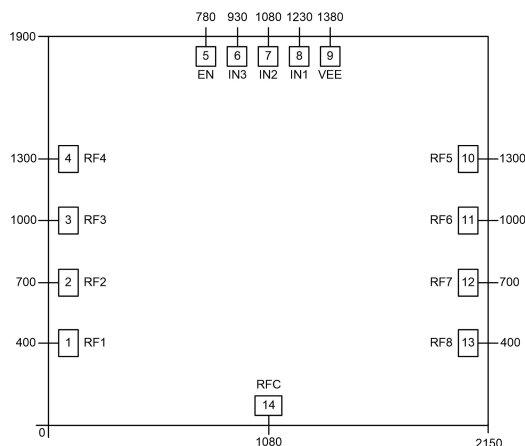


Full off isolation



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Appearance and structure ( units in the figure are all microns )



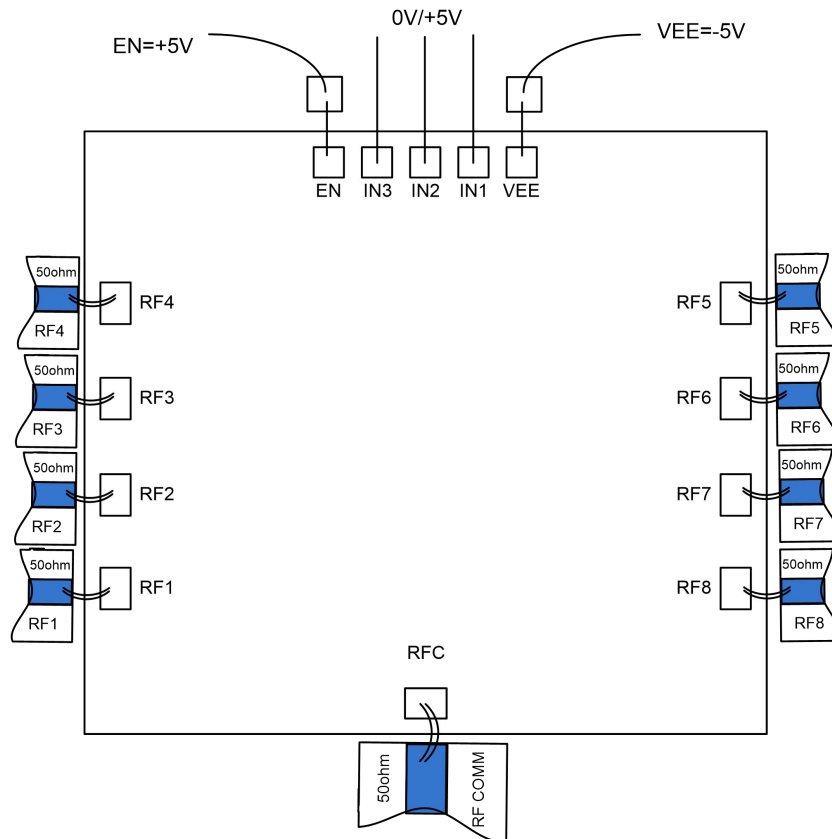
### Bonding point definition

Bonding point number	Function Symbol	Functional Description
14	RF COMM	RF common terminal , internal integrated DC blocking capacitor
1, 2, 3, 4, 10, 11, 12, 13	RF1~RF8	RF input/output terminal , internal integrated DC blocking capacitor
8, 7, 6	IN1~IN3	Signal control port, on/off control
5	EN	Enable end
9	VEE	Power supply terminal
Chip bottom	GND	The bottom of the chip needs to be well grounded to RF and DC

Truth table :

VEE (V)	EN(V)	Control Input			Signal Path State
		IN3(V)	IN2(V)	IN1(V)	
-5	0	Low (0)	Low (0)	Low (0)	RFC-RF1
		Low (0)	Low (0)	High (1)	RFC-RF2
		Low (0)	High (1)	Low (0)	RFC-RF3
		Low (0)	High (1)	High (1)	RFC-RF4
		High (1)	Low (0)	Low (0)	RFC-RF5
		High (1)	Low (0)	High (1)	RFC- RF6
		Low (0)	High (1)	High (1)	RFC- RF7
	High (1)	High (1)	High (1)	RFC- RF8	
	+5	-	-	-	All Off

## Recommended assembly drawing



Note: The VEE port can be connected in parallel with a bypass capacitor > 100nF .

## Precautions for use

- The chip needs to be stored in an anti-static container and kept in a nitrogen environment.
- bare die surface using wet chemical methods .
- Please strictly comply with ESD protection requirements to avoid electrostatic damage to bare chips.
- General operation: Please use precision pointed tweezers to pick up bare chips. Avoid touching the chip surface with tools or fingers during operation.
- Rack mounting operation suggestions: Bare chip mounting can be done by AuSn solder eutectic sintering or conductive adhesive bonding. The mounting surface must be clean and flat.
- Sintering process: It is recommended to use AuSn solder sheets with a gold-tin ratio of 80/20 . The working surface temperature reaches 255 °C and the tool ( vacuum chuck ) temperature reaches 265 °C. When the high-temperature mixed gas (nitrogen-hydrogen ratio of 90/10 ) is blown to the chip, the temperature at the top of the tool should be raised to 290 °C. Do not let the chip exceed 320 °C for more than 20 seconds. The friction time should not exceed 3 seconds.
- Bonding process: The amount of conductive glue dispensed should be as small as possible. After the chip is placed in the installation position , the conductive glue should be vaguely visible

around it . For curing conditions, please follow the information provided by the conductive glue manufacturer.

- Bonding operation suggestions: Use  $\Phi 0.025\text{mm}$  (1mil) gold wire for both ball and wedge bonding . Thermo-ultrasonic bonding temperature is  $150\text{ }^{\circ}\text{C}$ . The pressure of the wedge for ball bonding is 40~50gf , and the pressure of the wedge bonding is 18~22gf . Use the smallest possible ultrasonic energy. The bonding starts at the pressure point on the chip and ends at the package (or substrate) .